[10191/955]

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventor(s)

Joerg SCHAEFER et al.

Serial No.

09/238,262

Filed

January 27, 1999

For

METHOD OF PRODUCING STRUCTURED WAFERS

Examiner

Anita Karen Alanko .

Art Unit

1746

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Commissioner for Patents Washington, D.C. 20231

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## AMENDMENT AFTER FINAL OFFICE ACTION

SIR:

In response to the Final Office Action dated September 30, 2002, kindly amend the above-identified application as set forth below. Entry of the amendment is requested since it raises no new issues and puts the claims in condition for allowance and/or in better form for appeal.

## IN THE CLAIMS:

Kindly amend claim 14 as follows:

(Amended) A method of etching a wafer, comprising the steps of:

providing a wafer having a surface and edge areas; dividing the surface of the wafer into positive areas and negatite areas, the negative areas including the edge areas of the wafer;

providing the negative areas with a first passivation layer to protect the negative areas from a subsequent second etching process;

providing at least one of the positive areas with a

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PROCEINE!